

## Electronic Supplementary Information

### **A high-performance broadband double-junction photodetector based on silicon nanowire arrays wrapped by silver nanoparticles for low-light imaging**

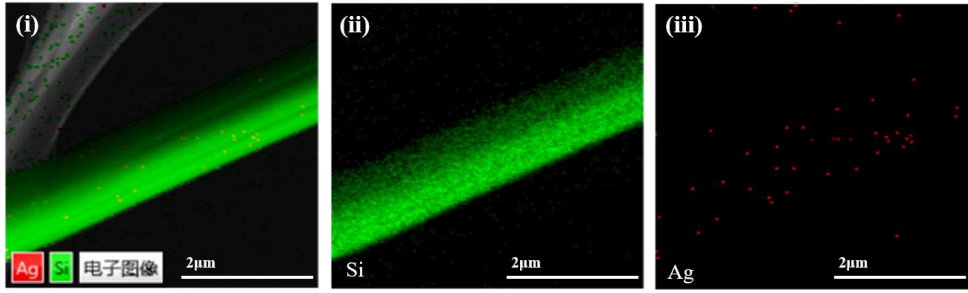
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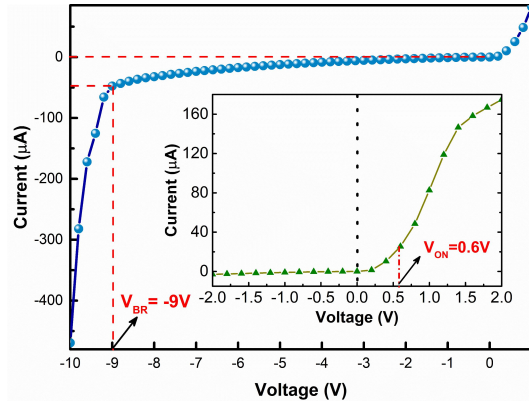
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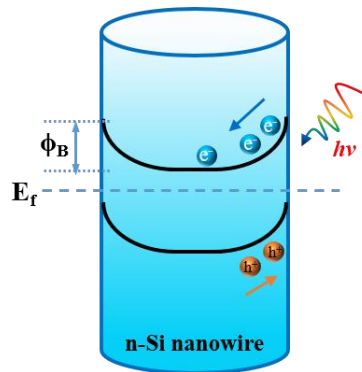
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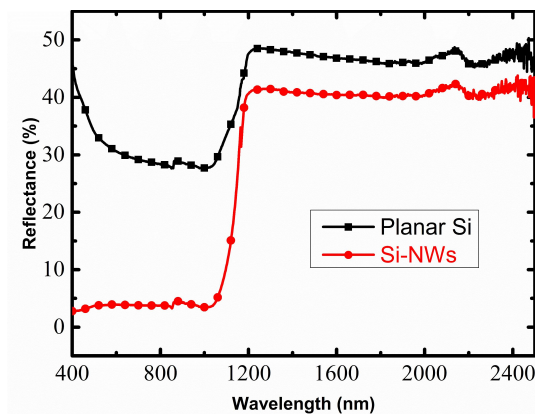
**Fig. S1** Energy spectrum mapping of (i) silicon and silver elements of layer image, (ii) silicon and (iii) silver elements.



**Fig. S2**  $I$ - $V$  characteristic curve of the device measured in 650 nm irradiation, the breakdown voltage was approximately -9 V, and the inset shows the turn-on voltage was 0.6 V.



**Fig. S3** Nanowire surface band bending and photogenerated carriers are separated under illumination,  $\phi_B$  the recombination barrier.



**Fig. S4** UV-vis-NIR reflectance spectra of the SiNW arrays and planar Si.

**Table S1.** Comparison of the typical figure of merits between our NN<sup>+</sup>/MS double junction enhanced SiNWs@AgNPs photodetector and other reported the nanowire silicon-based devices, mainly including  $R$ , Response wavelength range,  $D^*$ ,  $I_{dark}$ , response speed (rise/fall time), and weak light sensitivity (low light intensity that can be detected).

Category	Devices	$R$ [A/W]	Photo- response range [ $\mu\text{m}$ ]	$D^*$ [cm Hz <sup>1/2</sup> /W]	$I_{dark}$ [A]	Rise/fall time [ $\mu\text{s}$ ]	Low power intensity	Ref.
Junction structure	p-SiNWs/nCdS nanoparticles	0.821 @900 nm	0.2-1.1	$1.21 \times 10^{12}$	$\sim 2 \times 10^{-7}$	203 ms/ 429 ms	$8 \mu\text{W}/\text{cm}^2 \sim$ $1 \text{ mW}/\text{cm}^2$	1
	PdSe <sub>2</sub> /SiNWA	0.726 @980 nm	0.2–2	$3.19 \times 10^{14}$	$\sim 10^{-10}$	3.4/3.9	$27.5 \sim 56.6$ $\text{nW}/\text{cm}^2$	2
	MoS <sub>2</sub> /Al <sub>2</sub> O <sub>3</sub> /SiN Ws	0.61 @808 nm	0.3-1.6	$1.48 \times 10^{12}$	$\sim 10^{-9}$	8.4/40.9	$1.4 \text{ nW}/\text{cm}^2 \sim$ $714.3 \text{ mW}/\text{cm}^2$	3
	perovskite nanowires/Au	37.14 @473 nm	0.35-0.9	$2.06 \times 10^{13}$	$\sim 10^{-10}$	91/563	$1.45 \text{ nW}/\text{cm}^2 \sim$ $145 \text{ mW}/\text{cm}^2$	4
plasmonic enhanced detector	AgNP/SiOx NW/Si	1.54 @370nm	0.3-0.85	$2.12 \times 10^{10}$	$\sim 10^{-10}$	0.12s/ 0.11s	/	5
	rGO: AuCQD/Si NW	0.5 @940nm	0.36-0.94	$1.4 \times 10^{12}$	$\sim 10^{-10}$	750ms/ 667ms	$0.2 \mu\text{W}/\text{cm}^2 \sim$ $0.6 \text{ mW}/\text{cm}^2$	6
	MoS <sub>2</sub> /AgNPs/Si NWs	402.4 @532nm	0.405- 0.635	$2.34 \times 10^{12}$	$\sim 10^{-4}$	41ms/ 37ms	$0.13 \sim 231.7$ $\text{mW}/\text{cm}^2$	7
	Au antennas/All- Si	0.05 @980nm	0.8-1.6	$2 \times 10^{11}$	/	/	/	8
	Perovskite/Au squares/Si/SiO	4.2 @800nm	0.6-0.9	$7.1 \times 10^{11}$	$\sim 10^{-9}$	/	$1 \text{ mW}/\text{cm}^2$	9
	rGO/CQD/AgNP /Si	0.3 @940nm	0.36-0.94	$4.1 \times 10^{11}$	$\sim 10^{-9}$	556 ms/ 526 ms	$1 \mu\text{W}/\text{cm}^2 \sim$ $1 \text{ mW}/\text{cm}^2$	10
NN <sup>+</sup> /MS double junction structure and plasmonic enhanced	SiNWs/AgNPs	2.2 @980nm	0.254-2.2	$5.1 \times 10^{14}$	$\sim 2 \times 10^{-12}$	25/62	$1.4 \text{ nW}/\text{cm}^2 \sim$ $64.3 \text{ mW}/\text{cm}^2$	This work

$R$ ,  $D^*$ , and  $I_{dark}$  represent responsivity, specific detectivity, and dark current, respectively. rGO and CQD represent reduced graphene oxide, quantum dot.

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